

LOCTITE ABLESTIK 8360

August 2021

PRODUCT DESCRIPTION

LOCTITE ABLESTIK 8360 provides the following product characteristics:

| | |
|------------------|--|
| Technology | Epoxy |
| Appearance | Silver |
| Cure | Heat cure |
| Product Benefits | <ul style="list-style-type: none"> Excellent dispensability, minimal tailing and stringing Box oven cure Minimal resin bleed Low condensable volatiles High purity Electrically conductive |
| Application | Die attach |
| Filler Type | Silver |
| pH | 4.2 |

LOCTITE ABLESTIK 8360 die attach adhesive is designed for high reliability packaging applications. The unique properties result in superior autoclave reliability test performance of the final assembled devices.

MIL-STD-883

LOCTITE ABLESTIK 8360 meets the requirements of MIL-STD-883, Method 5011.

TYPICAL PROPERTIES OF UNCURED MATERIAL

| | |
|---|-------|
| Thixotropic Index (0.5/5 rpm) | 4.2 |
| Viscosity, Brookfield CP51, 25 °C, mPa·s (cP): | |
| Speed 5 rpm | 7,900 |
| Work Life @ 25°C, hours | 20 |
| Shelf Life @ -40°C (from date of manufacture), days | 365 |

TYPICAL CURING PERFORMANCE

Cure Schedule

1 hour @ 175°C

Alternative Cure Schedule for Metal Leadframe Die Attach

5°C per minute ramp to 175°C + 1 hour @ 175°C

Alternative Cure for BGA Die Attach

2 hours @ 100°C + 30 minute ramp to 175°C +
1 hour @ 175°C

Weight Loss on Cure

10 x 10 mm Si die on glass slide, % 3.4

Both cure options were observed to yield reduced bondline voiding and increased strength. Dwell at low temperature is recommended to allow vaporization of diluents prior to gelation

The above cure profiles are guideline recommendations. Cure

conditions (time and temperature) may vary based on customers' experience and specific application requirements, as well as customer curing equipment, oven loading and actual oven temperatures.

TYPICAL PROPERTIES OF CURED MATERIAL

Physical Properties

| | | |
|--|----------------------------|--------------------|
| Coefficient of Thermal Expansion, : | | |
| Below Tg, ppm/°C | 45 | |
| Above Tg, ppm/°C | 200 | |
| Glass Transition Temperature (Tg) by TMA, °C | | |
| Thermal Conductivity @ 121°C, W/(m-K) | | |
| Tensile Modulus, DMTA : | | |
| @ -65 °C | N/mm ² (psi) | 5,800 (840,000) |
| @ 25 °C | N/mm ² (psi) | 5,000 (730,000) |
| @ 150 °C | N/mm ² (psi) | 360 (52,000) |
| @ 250 °C | N/mm ² (psi) | 270 (39,000) |

Extractable Ionic Content, @ 100°C:

| | |
|--|-----|
| Chloride (Cl-) | <20 |
| Sodium (Na+) | <10 |
| Potassium (K+) | <5 |
| Water Extract Conductivity, µmhos/cm | |
| Weight Loss @ 300°C, % | |
| Moisture Absorption @ Saturation, wt.% @ 0.55 85°C/85°RH | |

Electrical Properties

| | |
|-----------------------------|--------|
| Volume Resistivity, ohms-cm | 0.0005 |
|-----------------------------|--------|

TYPICAL PERFORMANCE OF CURED MATERIAL

Miscellaneous

Die Shear Strength:

| | |
|------------------------|----|
| 2 X 2 mm Si die, kg-f, | |
| Ag/Cu leadframe | 11 |

3 X 3 mm Si die, kg-f,

*Data generated using alternate ramp cure condition

| Substrate | @25°C | @200°C | @250°C |
|-------------------|-------|--------|--------|
| Ag/Cu LF | 29 | 1.3 | 1.0 |
| Bare Cu LF | 9.0 | 0.82 | 0.56 |
| Pd/Ni/Cu LF | 17 | 1.3 | 0.87 |
| Au BT-Resin Board | 32* | 3.5* | 2.5* |



3 X 3 mm Si die, kg-f,

After 85°C/85% RH exposure for 168 hours

| Substrate | @25°C | @200°C |
|-------------|-------|--------|
| Ag/Cu LF | 25 | 1.3 |
| Bare Cu LF | 10 | 0.7 |
| Pd/Ni/Cu LF | 19 | 1.3 |

3 X 3 mm Si die, kg-f,

After 30°C/60% RH exposure for 192 hours

*Data generated using alternate ramp cure condition

| Substrate | @25°C | @200°C |
|-------------------|-------|--------|
| Au-BT Resin Board | 26* | 2.1* |

Chip Warpage vs Chip Size:0.38 mm thick Si die on 0.2 mm thick Ag/Cu LF @ 25°C, μm

| Chip Size: | Warpage: |
|---------------|----------|
| 7.6 x 7.6mm | 10 |
| 10.2 x 10.2mm | 18 |
| 12.7 x 12.7mm | 26 |

0.38 mm thick Si die on 0.48 mm Au BGA @ 25°C, μm

| Chip Size: | Warpage: |
|---------------|----------|
| 7.6 x 7.6mm | 10 |
| 10.2 x 10.2mm | 23 |

Chip Warpage vs Post Cure Thermal Process:7.6 x 7.6 x 0.38 mm Si die on 0.2 mm thick Ag/Cu LF, μm

| Post Cure | + Wirebond (1 min @ 250°C) | +Post Mold Bake (4 hrs @ 175°C) |
|-----------|-------------------------------|------------------------------------|
| 12 | 15 | 15 |

7.6 x 7.6 x 0.38 mm Si die on 0.48 mm thick Au BGA, μm

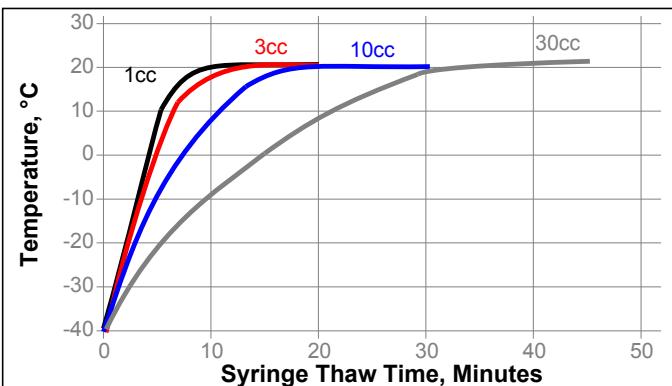
| Post Cure | + Wirebond (1 min @ 250°C) | +Post Mold Bake (4 hrs @ 175°C) |
|-----------|-------------------------------|------------------------------------|
| 10 | 11 | 9.2 |

GENERAL INFORMATION

For safe handling information on this product, consult the Safety Data Sheet, (SDS).

Thawing

1. Allow container to reach room temperature before use.
2. After removing from the freezer, set the syringes to stand vertically while thawing.
3. Refer to the Syringe Thaw time chart for the thaw time recommendation.
4. DO NOT open the container before contents reach 25°C temperature. Any moisture that collects on the thawed container should be removed prior to opening the container.
5. DO NOT re-freeze. Once thawed to -40°C, the adhesive should not be re-frozen.

**Directions for Use**

1. Thawed material should immediately be placed on dispense equipment for use.
2. If the adhesive is transferred to a final dispensing reservoir, care must be exercised to avoid entrapment of contaminants and/or air into the adhesive.
3. Adhesive must be completely used within the product's recommended work life.
4. Silver-resin separation may occur if the adhesive is left out at room temperature, beyond the recommended work life.
5. Apply enough adhesive to achieve a 25 to 50 μm wet bondline thickness, dispensed with approximately 25 to 50 % filleting on all sides of the die.
6. Alternate dispense amounts may be used depending on the application requirements.
7. Star or crossed shaped dispense patterns will yield fewer bondline voids than the matrix style of dispense pattern.
8. Organic substrates should be dried prior to die bonding. High moisture content in organic Ball Grid Array (BGA) substrates may cause excessive voiding and/or die delamination during the adhesive cure process. A minimum drying condition of 2 hours at 125°C is recommended for BGA substrates.
9. Oven should be pre-heated to 175°C before introducing the leadframe magazines.

Not for product specifications

The technical data contained herein are intended as reference only. Please contact your local quality department for assistance and recommendations on specifications for this product.

Storage

Store product in the unopened container in a dry location. Storage information may be indicated on the product container labeling.

Optimal Storage: -40 °C. Storage below minus (-)40 °C or greater than minus (-)40 °C can adversely affect product properties.

Material removed from containers may be contaminated during use. Do not return product to the original container. Henkel Corporation cannot assume responsibility for product which has been contaminated or stored under conditions other than those previously indicated. If additional information is required, please contact your local Henkel Representative.

Conversions

$(^{\circ}\text{C} \times 1.8) + 32 = ^{\circ}\text{F}$
 $\text{kV/mm} \times 25.4 = \text{V/mil}$
 $\text{mm} / 25.4 = \text{inches}$
 $\text{N} \times 0.225 = \text{lb/F}$
 $\text{N/mm} \times 5.71 = \text{lb/in}$
 $\text{psi} \times 145 = \text{N/mm}^2$
 $\text{MPa} = \text{N/mm}^2$
 $\text{N}\cdot\text{m} \times 8.851 = \text{lb}\cdot\text{in}$
 $\text{N}\cdot\text{m} \times 0.738 = \text{lb}\cdot\text{ft}$
 $\text{N}\cdot\text{mm} \times 0.142 = \text{oz}\cdot\text{in}$
 $\text{mPa}\cdot\text{s} = \text{cP}$

Disclaimer**Note:**

The information provided in this Technical Data Sheet (TDS) including the recommendations for use and application of the product are based on our knowledge and experience of the product as at the date of this TDS. The product can have a variety of different applications as well as differing application and working conditions in your environment that are beyond our control. Henkel is, therefore, not liable for the suitability of our product for the production processes and conditions in respect of which you use them, as well as the intended applications and results. We strongly recommend that you carry out your own prior trials to confirm such suitability of our product.

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Reference 0.3